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PPLICATION NO	).	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/706,986		11/14/2003	Setsuo Nakajima	0756-7220	7488
31780	7590	05/09/2005		EXAMINER	
ERIC RO	BINSON		NGUYEN, TUAN H		
PMB 955 21010 SOUTHBANK ST.				ART UNIT PAPER NUMBE	
POTOMA	OTOMAC FALLS, VA 20165			2813	
				DATE MAILED: 05/09/2009	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
	10/706,986	NAKAJIMA ET AL.					
Office Action Summary	Examiner	Art Unit					
	Tuan H. Nguyen	2813					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timed within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	ely filed swill be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).					
Status		·					
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ This 3) ☐ Since this application is in condition for allowar	☐ This action is FINAL. 2b) ☐ This action is non-final.						
Disposition of Claims							
<ul> <li>4)  Claim(s) 1-51 is/are pending in the application.</li> <li>4a) Of the above claim(s) is/are withdraw</li> <li>5)  Claim(s) is/are allowed.</li> <li>6)  Claim(s) 1-51 is/are rejected.</li> <li>7)  Claim(s) is/are objected to.</li> <li>8)  Claim(s) are subject to restriction and/or</li> </ul>	vn from consideration.						
Application Papers							
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acce Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Examine	epted or b) objected to by the Eddrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).					
Priority under 35 U.S.C. § 119		•					
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No. 09/114,223.</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>							
Attachment(s)	•						
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 11/03, 12/03.</li> </ol>	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:						

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### **DETAILED ACTION**

## Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-51 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-44 of U.S. Patent No. 6,242,290. Although the conflicting claims are not identical, they are not patentably distinct from each other because the instant claimed method for fabricating an electronics device including the step of crystallizing a silicon film by the action of a metal for promoting crystallization of silicon, and gettering the metal element existed in the silicon film by heating with the use of a film containing the XV group element has been disclosed and claimed by Patent No. 6,242,290. The subsequent step of forming a CMOS as claimed, is well-known and it would have been obvious to those skilled in the art to recognize that CMOS is inherently included in the formation of EL display or other electronic systems as claimed in claims 37-44 of the patent.

## Claim Objections

Claims 19, 45-51 are objected to because of the following informalities:

In claim 19, "said XV group element" lacks antecedent basis.

In claims 45-51, "said CMOS circuit" lacks antecedent basis.

Appropriate correction is required.

Claims 45-51 are objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim.

Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form.

"a CPU" is not recited in the previous claims, and not further limit the method of fabricating an electronics device in the previous claims.

### Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) and the Intellectual Property and High Technology Technical

Amendments Act of 2002 do not apply when the reference is a U.S. patent resulting

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directly or indirectly from an international application filed before November 29, 2000. Therefore, the prior art date of the reference is determined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

Claims 1-7, 22-25, 31-51 are rejected under 35 U.S.C. 102(e) as being anticipated by Yamazaki et al..

See Yamazaki et al., figs. 8A-9C and text on col. 3-14 which discloses the claimed method for forming a CMOS for use in EL display or other electronic systems (claims 39-40), including the steps of crystallizing silicon film 802 with the use of nickel 803 for promoting crystallization to form a crystalline silicon film 804 (figs. 8A-8B and related text); forming a film 807, 808, 809 comprising XV group element (col. 6, second and third paragraphs) of phosphorus over and in contact with the semiconductor film 804 (fig. 8D); irradiating an infrared light (col. 5, lines 29-30) by lamp heating system (as shown in figs. 3A-3B) to the semiconductor film to getter the metal from the silicon film 804 into the film 807, 808, 809 comprising group 15 element (fig. 8D and related text); patterning the semiconductor film to form at least first and second semiconductor islands 810, 811 after the irradiation (fig. 8E and related text); forming CMOS device including at least an n-channel and a p-channel thin film transistors using at least firs and second semiconductor islands (figs. 8F-9C).

With respect to claims 37-51, see figs. 6-7 and related text on col. 12.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 571-272-1694. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tuan H. Nguyen Primary Examiner Art Unit 2813